Back On Track



Michael A. Fury, Ph.D.
Techcet Group LLC
July 11, 2012

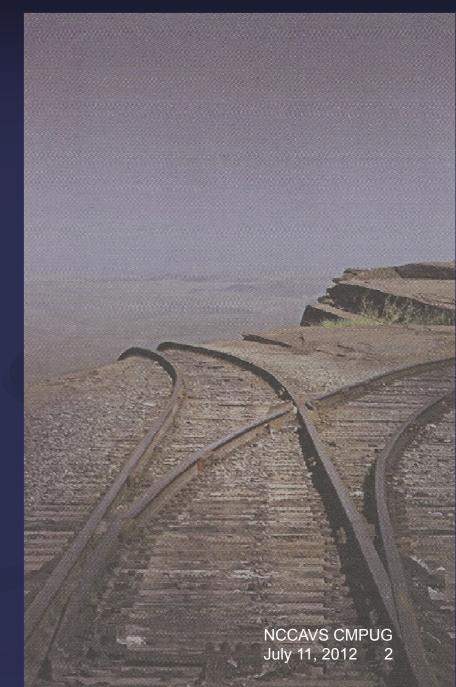


*MFury@Techcet.com 415-395-6945*www.techcet.com

Outline

*The Business

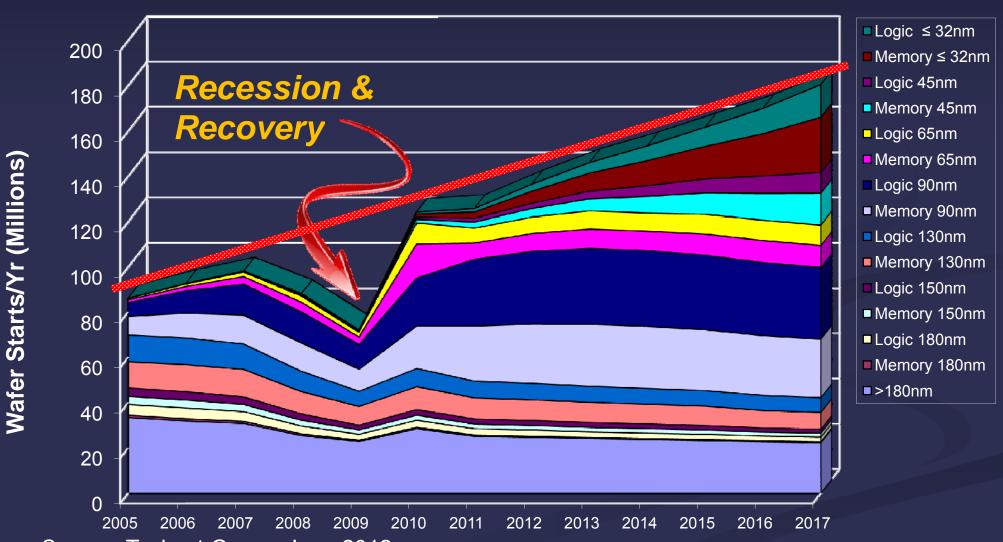
*The Buzz





The Business of Semiconductors

Annual Wafer Starts (200mm equivalents)

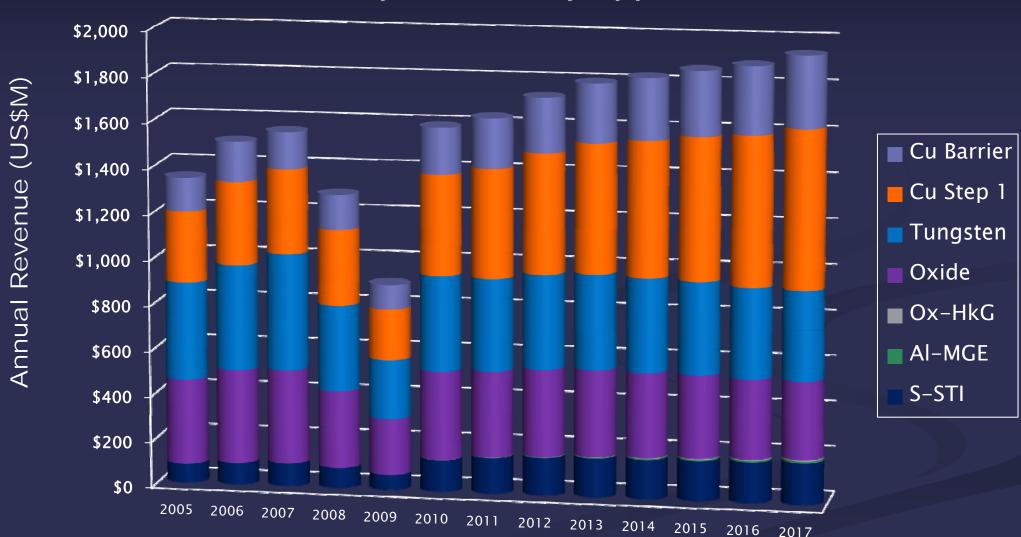


Source: Techcet Group, June 2012



The Business of CMP

Pad & Slurry Revenue by Application



Source: Techcet Group, June 2012



The Business of CMP

- * Modest revenue growth for 2011
 - + Up 3% over 2010's 76% recovery blast
 - + 2012 forecast: +5.7% to \$1.73B; new processes
 - + 5-year CAGR: 2.8%
- * Revenue shuffle continues
 - + More copper & STI, less tungsten & ILD
 - + Resurgence of premium silica markets
 - + New applications emerging for ceria
- * No entries/exits in CMP supplier base



The Players - Slurry

- * Air Products buys DuPont's DANM share
 - + DANM / Cabot IP settlement has had little effect
- No significant share movement in 2011
- * > 15 suppliers share \$994M market (est. 2012)
 - + Tier 1 Cabot Microelectronics ~40% share
 - + Tier 2 DANM, Dow, FujiFilm, Fujimi, Hitachi
 - + Tier 3 Anji, AGC, ATMI, BASF, Bayer, Cheil, Ferro, JSR, Wacker
 - ▲ Shares < 5%



The Players - Slurry

- *July, 2011: proposed a CMP slurry market statistics program
 - Modeled after SEMI silicon wafer and photoresist programs
 - + All key suppliers invited to participate
 - + Zero participants signed up

* CMP market statistics will continue to be consensus estimates



The Players - Pads

- * No significant share movement in 2011
- *>16 makers share \$646M market (est. 2012)
 - + Tier 1 Dow ~80% share
 - + Tier 2 Cabot ~5-10% share

 - + Others 3M, Fujibo, IVT, KPX, NexPlanar, Rogers, SKC, Toray, Toyo, Toyobo

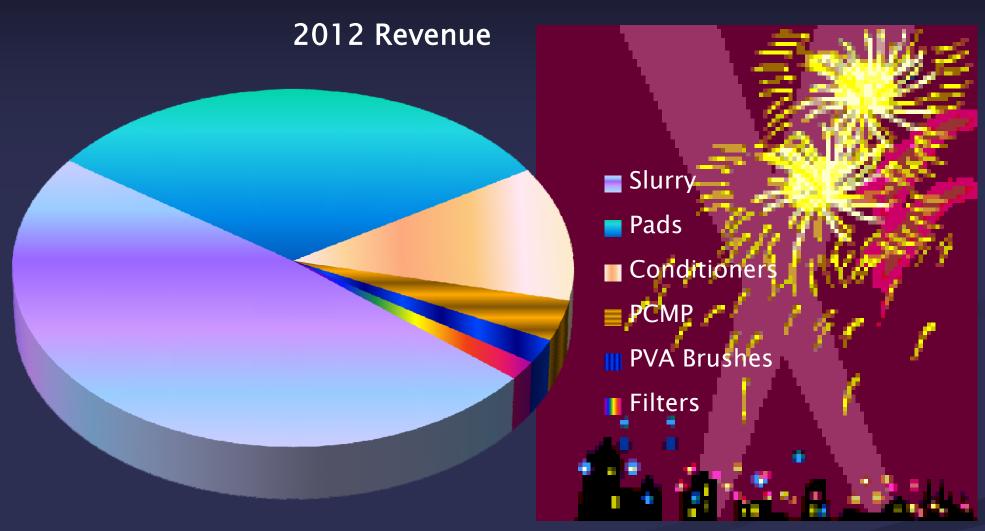


The Players – Other CMP

- * Pad conditioners ~\$250M market
 - +3M & Kinik combined share >50%
- * PCMP Cleaners ~\$75M market
 - + ATMI & Air Products combined share >65%
- * PVA brushes ~\$45M market
 - +ITW & Aion combined share >80%
- - + Pall & Entegris combined share >90%



CMP Consumables Grand Total



Total CMP Consumables: ~\$2.04B



The Buzz – Ceria & China

- * Ceria remains highly cost competitive due to China's export restrictions
 - + 10-30% jump in ceria slurry prices
 - + Slurry suppliers more engaged in refining
 - + Alternative mines reopening globally
- * New FEOL device structures leverage ceria rate, selectivity, defectivity
 - + Same abrasive, different additives
 - +~1% solids for S-STI, less for new FEOL



The Buzz – Defect Reduction

- Reducing microscratching at STI and other FEOL steps is a critical issue below 32nm - crazy sensitive
 - + Real-time slurry monitoring brings 6σ line control capability to CMP (Vantage Tech)
 - + Customers asking for post-polish debris analysis for scratching incident diagnosis
 - + New metrology and hardware will need new line management protocols to be effective



The End

- * CMP consumables market has returned to its pre-recession trajectory
- * CMP growth rate will *once again* exceed semiconductor growth for the next 3-5 years as new device structures call for new CMP processes
- * CMP process yield will benefit from metrology innovations



The Techcet Group, LLC

Techcet Partners
Karey Holland, Ph.D.
Steven Holland, Ph.D.
John Housley
Lita Shon-Roy

Technology & Market Analysts
Michael Fury, Ph.D.
Jiro Hanaue
Maggie Lee
Gary Ray, Ph.D.
Larry Thompson, Ph.D.
Allan Wiesnoski





The Techcet Group, LLC

* 2012 CMP Consumables Report

- + New: available by individual consumable
- + New: some content available by the page
- + Lita Shon-Roy
 - ▲480-336-2160 orders
 - ▲480-275-3101 fax orders
 - LShonRoy@Techcet.com
 - www.Techcet.com

